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Dynamic Tilting of Ferroelectric Domain Walls Caused by Optically Induced Electronic Screening

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Optical excitation perturbs the balance of phenomena selecting the tilt orientation of domain walls within ferroelectric thin films. The high carrier density induced in a low-strain BaTiO₃ thin film by an above-band-gap ultrafast optical pulse changes the tilt angle that 90° *a/c* domain walls form with respect to the substrate-film interface. The dynamics of the changes are apparent in time-resolved synchrotron x-ray scattering studies of the domain diffuse scattering. Tilting occurs at 298 K, a temperature at which the *a/b* and *a/c* domain phases coexist but is absent at 343 K in the better ordered single-phase *a/c* regime. Phase coexistence at 298 K leads to increased domain-wall charge density, and thus a larger screening effect than in the single-phase regime. The screening mechanism points to new directions for the manipulation of nanoscale ferroelectricity.

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Nanoscale-thickness regions near ferroelectric domain walls exhibit properties that are distinct from bulk or thin-film ferroelectric materials due to the rapid spatial variation of the polarization and inhomogeneous distortion of the crystal lattice [1,2]. The dramatically different electronic properties of domain-wall regions arise largely from two effects. First, a step in the electrostatic potential and a related high density of bound charges can arise at domain walls [3,4]. In addition, inhomogeneous strain or oxygen octahedral rotation near domain walls can modify the band structure via the deformation potential and flexoelectric coupling [5–7]. These effects can lead, for example, to room-temperature electrical conductivity in otherwise insulating ferroelectrics and to the formation of a two-dimensional electron gas [8–10]. The electrostatic potential step can separate photoexcited electron-hole pairs and contribute to the generation of photovoltages larger than the electronic band gap [3,11–13]. The novel phenomena associated with domain walls make it important to probe how the physical properties of nanoscale volumes near domain walls evolve under external stimuli. In this Letter, we show that elastic heterogeneity introduced by a coexistence of two different types of ferroelastic domain patterns leads to unusual nanosecond-timescale responses of domain-wall configuration to femtosecond-duration optical pulses.

The orientation of domain walls with respect to crystallographic directions, surfaces, or interfaces depends on multiple contributions to the free energy, including stress

and the density of bound charges [2,14]. In addition to these unit-cell-scale effects, the bound charge density can also arise from mesoscopic geometric deviations from the ideal domain configuration such as domain-wall roughness [7,14]. The dependence of the bound charge density on this disorder in the domain configuration leads to an intriguing link between electronic or optoelectronic effects and the domain-pattern phase diagram.

We report an optically induced modulation of the electrostatic energy contribution to the domain-wall energy. The experimental signature of this modulation is a change in the angle formed between the plane of domain walls in a BaTiO₃ (BTO) thin film and the surface, termed the tilt angle α . The change in α occurs on the single-nanosecond timescale following excitation by an ultrafast optical pulse and relaxes over several nanoseconds. Changes in the electrostatic contribution to the free energy can occur through screening of the bound charge by mobile charges, including those created by optical absorption [2]. The origin of the bound charges is apparent in the temperature dependence of the experimental observation. The tilting occurs at a temperature at which there is a coexistence of multiple domain configurations and a resulting deviation from the ideal zero-bound-charge domain arrangement.

Experiments probing the optically induced domain-wall tilting used an epitaxial 78 nm-thick BTO film on a 6 nm-thick SrRuO₃ layer on an NdScO₃ (NSO) substrate, as in Fig. 1(a) [15]. The scattered x-ray intensity was analyzed using reciprocal-space coordinates Q_x , Q_y , and Q_z along

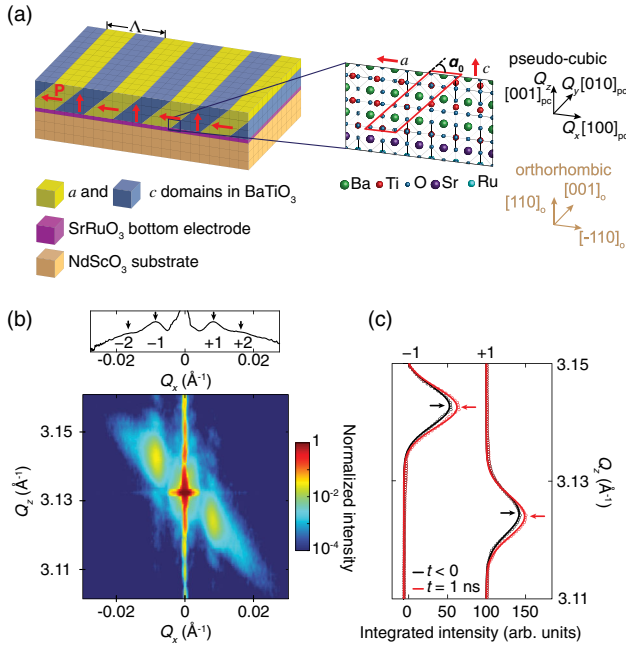


FIG. 1. (a) BTO thin film with arrangement and atomic structure of a/c domain pattern. (b) Scattered x-ray intensity in the $Q_x - Q_z$ section of reciprocal space at $Q_y = 0$. The BTO 002 reflection is at $Q_z = 3.13 \text{ \AA}^{-1}$. Intensity oscillations corresponding to the BTO thickness are along Q_z at $Q_x = 0$. The intensity distribution along Q_x (inset) is obtained by integrating the intensity with respect to Q_z . The ± 1 and ± 2 orders of domain scattering appear at $Q_x = \pm 0.008 \text{ \AA}^{-1}$ and $\pm 0.016 \text{ \AA}^{-1}$. (c) Intensity profiles of -1 and $+1$ orders of domain scattering before optical excitation ($t < 0$) and at $t = 1 \text{ ns}$ for $F_{\text{abs}} = 2.4 \mu\text{J}/\text{cm}^2$. The maximum-intensity values of Q_z are indicated with arrows at each time.

the $[100]$, $[010]$, and $[001]$ pseudocubic (PC) directions, which correspond to $[-110]$, $[001]$, and $[110]$ orthorhombic (O) directions in NSO, respectively. Directions are given here with subscripts indicating the basis.

In the temperature range probed in these experiments, the BTO layer can be generally described by means of two domain configurations: (i) a high-temperature a/c pattern with alternating orthogonal domains of in-plane and out-of-plane polarization, and (ii) an a/b pattern appearing below 340 K with stripes of orthogonal in-plane polarization. The a/c domain pattern has period Λ along $[100]_{\text{PC}}$ and equilibrium domain-wall tilt angle α_0 , as illustrated in Fig. 1(a)[15]. In addition to the a and c components of the polarization in Fig. 1(a), there are indications that the a/c pattern at 298 K also includes a small in-plane component a^* along $[010]_{\text{PC}}$ [16,17], such that the 298 K domain phase would be the predicted aa^*/ca^* configuration [16]. The a^* component is predicted to exhibit a 180° rotation at the a/c domain wall. Temperature-dependent x-ray diffraction measurements described in the Supplemental Material and piezoelectric force microscopy both indicate that a/c and a/b phases coexist over a temperature range of

tens of degrees below 340 K [18,19]. At 298 K, the majority of the volume of the BTO film is in the a/b phase. The transition from ferroelectric to paraelectric phases occurs at 403 K which is outside the temperature range of the experiments reported here [15].

Time-resolved synchrotron x-ray diffraction experiments were performed at station 7-ID-C of the Advanced Photon Source. The x-ray photon energy and pulse duration were 9 keV and 100 ps, respectively. The scattered intensity was measured in the three-dimensional volume of reciprocal space near the 002 BTO reflection. Femtosecond-duration laser pulses with 400 nm wavelength (optical photon energy $\hbar\omega = 3.1 \text{ eV}$) and absorbed fluence F_{abs} were synchronized with the x-ray pulses with variable delay t . The step size of the delay time used for the experiments ranges from 100 ps to 2 ns. Further details are in the Supplemental Material [20].

The x-ray intensity in a $Q_x - Q_z$ section of reciprocal space at $Q_y = 0$ near the 002 BTO reflection is shown in Fig. 1(b). A streak of intensity arising from the a/c domain pattern extends from high to low Q_z with increasing Q_x , forming an angle $\alpha_0 = 42^\circ$. Second-order diffraction intensity maxima at $Q_x = \pm 4\pi/\Lambda$ are apparent in the inset above Fig. 1(b). The intensity maxima have a separation of $2\pi/\Lambda = 0.008 \text{ \AA}^{-1}$ along Q_x at 298 K with $\Lambda = 78 \text{ nm}$. Domain scattering maxima are indexed with orders -2 , -1 , $+1$, and $+2$ such that maxima with negative Q_x have a negative order.

Optical excitation leads to an out-of-plane expansion of the BTO lattice parameter and to a change in α . The effect used to measure time dependence of the tilt angle $\alpha(t)$ is illustrated in Fig. 1(c) using the Q_z profiles of the -1 and $+1$ domain scattering at $t = 1 \text{ ns}$ for $F_{\text{abs}} = 2.4 \mu\text{J}/\text{cm}^2$. The intensity maxima of the -1 and $+1$ orders exhibit different optically induced fractional shifts of Q_z : -0.006% and -0.015% , respectively. The different shifts of the two orders indicate that there is a change in the angle of the domain scattering streak. At 1 ns the change is $\Delta\alpha(t = 1 \text{ ns}) = -0.5^\circ$ where $\Delta\alpha(t) = \alpha(t) - \alpha_0$. The negative value of $\Delta\alpha$ indicates that the angle that the domain wall forms with the substrate surface is slightly reduced. The area of the domain wall thus increases following optical excitation, as described in more detail below. The peak positions of the ± 1 orders of domain scattering along Q_x remain unchanged within the experimental uncertainty.

The time dependence of the distribution of scattered intensity along Q_z is shown for the ± 1 and ± 2 orders of the domain scattering in Figs. 2(a)–2(d) for $F_{\text{abs}} = 2.4 \mu\text{J}/\text{cm}^2$. The difference in the shifts of the ± 2 orders along Q_z are consistent with changes in α . The intensity variation observed in Fig. 2 can, in principle, arise from the photoinduced changes in magnitude of the ferroelectric polarization, either at the domain walls or in the remaining volume of the film [21,29,30]. The polarization depends on the off-centering of Ti ions within the

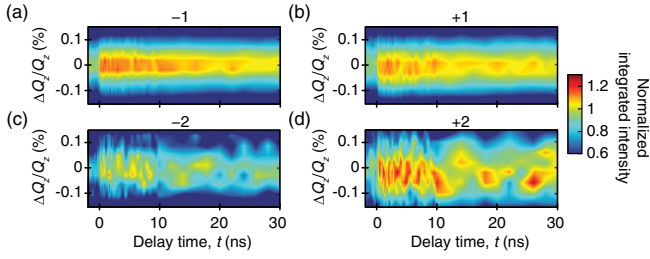


FIG. 2. Time dependence of the intensities of the (a) -1 , (b) $+1$, (c) -2 , and (d) $+2$ orders of domain scattering as a function of $\Delta Q_z/Q_z$ following optical excitation at $F_{\text{abs}} = 2.4 \mu\text{J}/\text{cm}^2$. $\Delta Q_z/Q_z = 0$ corresponds to wave vectors of the intensity maxima before optical excitation. Intensities are normalized to values before optical excitation for each order of domain scattering.

oxygen octahedra [31], on which the diffracted intensity in turn depends through the structure factor. The oscillation of the intensity appears to be an experimental artifact associated with a combination of the different discrete time steps used at different stages in the measurements in Fig. 2 and experimental uncertainty. Detailed discussion of the intensity changes, however, is outside the scope of this Letter.

The dynamics of the fractional changes in the maximum Q_z of the ± 1 orders of the domain scattering and the resulting $\Delta\alpha(t)$ are shown in Fig. 3(a) for $F_{\text{abs}} = 2.4 \mu\text{J}/\text{cm}^2$. $\Delta\alpha$ changes by -0.5° within 1 ns after excitation, followed by relaxation over tens of nanoseconds. The relaxation time is similar to the time constant for recombination of photoexcited carriers [32]. The sign of $\Delta\alpha$ is different from the shift expected due to heating because (i) heating from 298 K induces positive change in α and (ii) the change in tilt angle due to heating has a non-monotonic temperature dependence, as described in the Supplemental Material [20].

The tilting is not observed in scattering measurements conducted in the single-phase a/c regime at 343 K, providing an indication that the tilt is linked to features of the domain configuration. Figure 3(b) shows the time dependence of Q_z at intensity maxima of the $+1$ and -1 orders of domain scattering and the value of $\Delta\alpha(t)$ at 343 K for $F_{\text{abs}} = 6.5 \mu\text{J}/\text{cm}^2$. The intensity at both orders shifts by $\Delta Q_z/Q_z = -0.015\%$ at $t = 1$ ns, indicating that the lattice expansion is optically induced at 343 K, as at lower temperatures. The magnitudes of the shifts at both orders are equal, however, which reveals that $\Delta\alpha = 0$ at 343 K, even with higher optical fluence than at 298 K. The optical fluence dependences of $\Delta\alpha(t = 1 \text{ ns})$ at 298 and 343 K are shown in Fig. 3(c). The magnitude of $\Delta\alpha(t = 1 \text{ ns})$ increases as a function of F_{abs} at 298 K, reaching -0.85° at $5.0 \mu\text{J}/\text{cm}^2$. At 343 K, $\Delta\alpha(t = 1 \text{ ns})$ is zero within experimental uncertainty for optical fluences up to $15 \mu\text{J}/\text{cm}^2$.

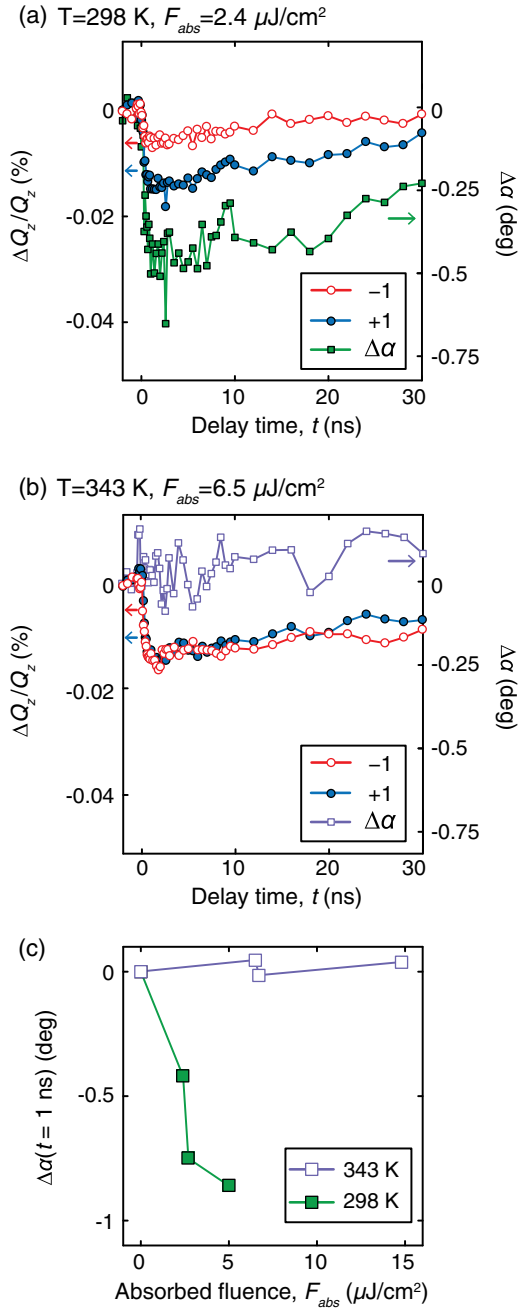


FIG. 3. Time dependence of fractional change of the wave vector Q_z of -1 and $+1$ orders of domain scattering at (a) 298 K for $F_{\text{abs}} = 2.4 \mu\text{J}/\text{cm}^2$ and (b) 343 K for $F_{\text{abs}} = 6.5 \mu\text{J}/\text{cm}^2$. (c) $\Delta\alpha(t = 1 \text{ ns})$ at $T = 298 \text{ K}$ and 343 K as a function of F_{abs} .

A model based on screening by photoinduced charge carriers accurately accounts for the observed tilting phenomenon and its dependence on experimental parameters. In the absence of bound charge, the domain pattern adopts a tilt orientation that minimizes the elastic energy. The head-to-tail orientation of the polarization in the a/c or a/b patterns nominally ensures that there is no net bound charge at the domain walls. Charged domain walls may, however, exist in BTO thin films due to deviations in the domain-

wall angle or the mesoscopic arrangement of domains walls, inhomogeneous stress on domain walls, and roughness of the domain walls [2,7,33]. Domain-wall roughening can arise from impurities, dislocations, and local strain gradients [34,35]. The domain-wall roughness can lead to the accumulation of bound charge at the small fraction of sites at which the polarization does not fulfil the local polarization continuity condition [14]. The magnitude of the bound charge density is much lower than would arise from the discontinuity of the total remnant polarization P_0 and varies significantly depending on the domain configuration [7]. Reported charge densities at roughened domain boundaries are on the order of 10% or less of the strongly charged case, a magnitude that can be screened by the photoinduced charge densities here [2,33]. The formation of bound charges may also arise from a discontinuity of the predicted a^* polarization component of the a/c phase. In this case, bound charge of a fraction of the predicted few- $\mu\text{C cm}^{-2}$ magnitude of the a^* component would arise in regions in which the in-plane direction of the domain walls is not aligned with the nominal $[010]_{\text{PC}}$ direction or at the boundaries between the a/c and a/b phases [15,16].

The substantial electrostatic energy per unit area of domain walls at which there is a nonzero density of bound charges causes the equilibrium configuration of domain walls to tilt toward the film surface with respect to the elastically preferred orientation in order to reduce the area of the domain wall and thus the charge density. Optically excited carriers screen the bound charges, leading to a reduction in electrostatic energy associated with charged domain walls and to a tilting of domain walls toward the substrate, as a result of which the domain-wall area increases. The carrier concentration induced by optically excited carriers for the experimental flux employed in Fig. 2 is $F_{\text{abs}}/\hbar\omega = 5 \times 10^{12} \text{ cm}^{-2}$, assuming that each absorbed photon produces one excited carrier. The optically induced charged density is orders of magnitude smaller than the bound charge density at strongly charged domain boundaries, which is on the order of P_0 , the equivalent of 10^{14} cm^{-2} . The photoinduced charge density would thus not be sufficient to screen a strongly charged domain wall. The BTO thin films considered here, however, have weakly charged walls with far smaller charge densities consistent with geometries that result in a nearly continuous polarization. In each possibility, namely roughness and disorder or the discontinuity of an a^* component, the magnitude of the bound charge is similar to the photoinduced charge density available for screening.

The disorder and coexistence of the domain patterns, and the link to a larger bound charge density at 298 K, is apparent in the intensity distribution in $Q_x - Q_y$ sections of reciprocal space, revealing the in-plane ordering of the domain patterns. The scattered intensity in $Q_x - Q_y$ sections at 298 and 343 K is shown in Figs. 4(a) and 4(b), respectively. Scattering from the a/c pattern appears along

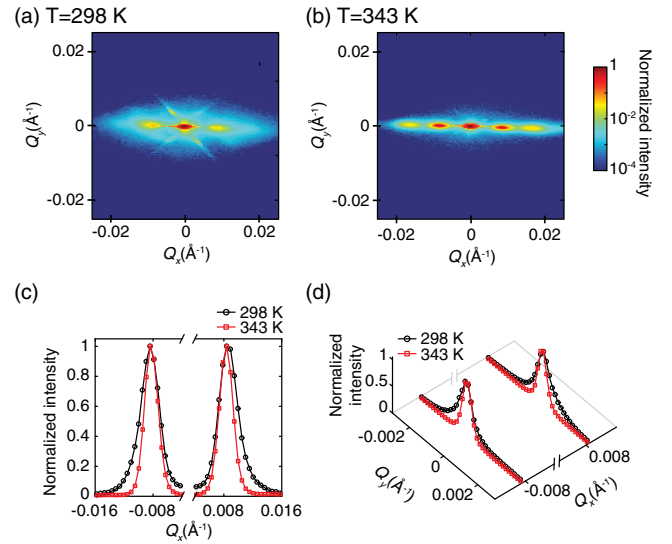


FIG. 4. Diffracted x-ray intensity distributions in the $Q_x - Q_y$ section at (a) 298 K and (b) 343 K. Intensity profiles of -1 and $+1$ orders of domain scattering along (c) Q_x and (d) Q_y at 298 and 343 K. The $Q_x - Q_y$ sections are obtained by integrating diffracted intensity distributions from $Q_z = 3.105$ to 3.16 \AA^{-1} .

the line at $Q_y = 0$ at both temperatures. Figure 4(a), acquired at 298 K, also has two additional pairs of intensity maxima distributed diagonally along $\langle 110 \rangle_{\text{PC}}$ directions arising from the a/b domain pattern. There are several differences in the scattering pattern in the configuration consisting of only the a/c phase at 343 K. The a/c pattern diffuse scattering exhibits a higher overall intensity and stronger ± 2 order maxima at 343 K due to the absence of the a/b pattern at this temperature.

The coexistence of the domain phases at 298 K leads to a structural distortion that is apparent in the reciprocal-space widths of the ± 1 orders of a/c domain scattering. The widths of the domain scattering intensity along Q_x and Q_y , shown in Figs. 4(c) and 4(d), are far larger than the natural width of the structural reflections because the domain period is coherent over a finite in-plane distance [36]. The in-plane coherence lengths along $[100]_{\text{PC}}$ and $[010]_{\text{PC}}$ calculated from the full width at half maximum (FWHM) of the domain scattering are 140 and 700 nm, respectively, at 298 K. The coherence lengths are 20% larger along both directions at 343 K than at 298 K. Coherence lengths measured using x-ray scattering include the effects of subtle variations in strain and domain period and are thus smaller than the size of domain phase regions observed using piezoelectric force microscopy [15]. The increased coherence length of the domain pattern at elevated temperature is somewhat counterintuitive because the roughness of the domain walls and domain disorder generally increase as a function of temperature [34,37]. In this case, however, the comparatively large widths at 298 K are consistent with the coexistence of the domain phases and resultant disorder.

We can also consider other mechanisms, besides the optically induced screening, that could potentially contribute to a change in the tilt angle of the domain walls. Optical absorption can lead both to photoinduced elastic strain in several ferroelectric materials [32,38] and, separately, to a reduction of the width of the a domain within the repeating unit of the striped a/c domain pattern [21]. To examine the change in α as a function of out-of-plane strain and a -domain width, we used thermodynamic models in which a continuous distribution of infinitesimal edge dislocations is employed to evaluate the energy associated with the elastic compatibility at domain walls. A detailed description of the models is provided in the Supplemental Material [20]. Briefly, the domain-wall free energy density was computed as a function of α and the width of the a domain component, including elastic contributions. The thermodynamic calculations show that a lattice expansion of 0.01%, as observed for $F_{\text{abs}} = 2.4 \mu\text{J}/\text{cm}^2$, leads to $\Delta\alpha = 0.001^\circ$, toward the substrate normal, a change with a far smaller magnitude and opposite sign to the observed effect. Similarly, a reduction of the width of the a domain could lead to a change in the tilt but by an order of magnitude lower than the measured $\Delta\alpha$. Neither of the alternative mechanisms besides screening is quantitatively consistent with the experimental observations.

The time to reach the maximum tilt decreased from 1.2 to 0.4 ns as the absorbed fluence increased in the range from 2.4 to 5 $\mu\text{J}/\text{cm}^2$, as shown in the Supplemental Material [20]. The 1 ns timescale is consistent with a mechanism in which there is a thermodynamic shift in the preferred value of α , followed by a kinetic response involving the motion of the domain boundaries to satisfy the new most favorable configuration. The time required for the initial change in $\Delta\alpha$ is compatible with the lateral motion of domain walls to facilitate the transformation. The change in angle requires domain boundaries to move on the order of nanometers, which is consistent with observed domain-wall velocities [39,40].

The time-resolved synchrotron x-ray diffraction experiments reported here reveal an electronic-screening-driven domain-wall tilting effect with a nanosecond characteristic timescale. The domain-wall tilting uniquely occurs in the domain configuration in which there is elastic heterogeneity near domain walls due to a coexistence of different domain patterns. The mechanism relating the domain tilting to domain-wall charging allows the tilting and other domain distortion effects to be used to probe the existence of domain-wall charge. The structural heterogeneity in complex domain patterns is, further, a route toward the discovery of unusual responses to external perturbations.

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